Recent developments in Speckle Angular Metrology (SAM) for X-ray mirrors at Diamond Light Source

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Introduction

A novel metrology instrument - Speckle Angular Measurement (SAM)¹ has been developed at Diamond Light Source. The precision achievable using SAM during the characterisation of X-ray optics is demonstrated to reach levels below 20 nrad. Additionally, we demonstrated the advantages of using SAM to X-ray mirror manufacturers. The benefits of this metrology instrument are:

- **✓** Able to characterise strongly curved optics
- **✓** Easy integration with LTP and NOM
- V Lasy integration with L11 and 110
- ✓ High precision✓ Portable device
- **✓** Developed using open-source software

✓ High accuracy

- **✓** Can provide 1D and 2D surface profile maps
- **✓** Low cost

Principle of Speckle angular measurement (SAM)

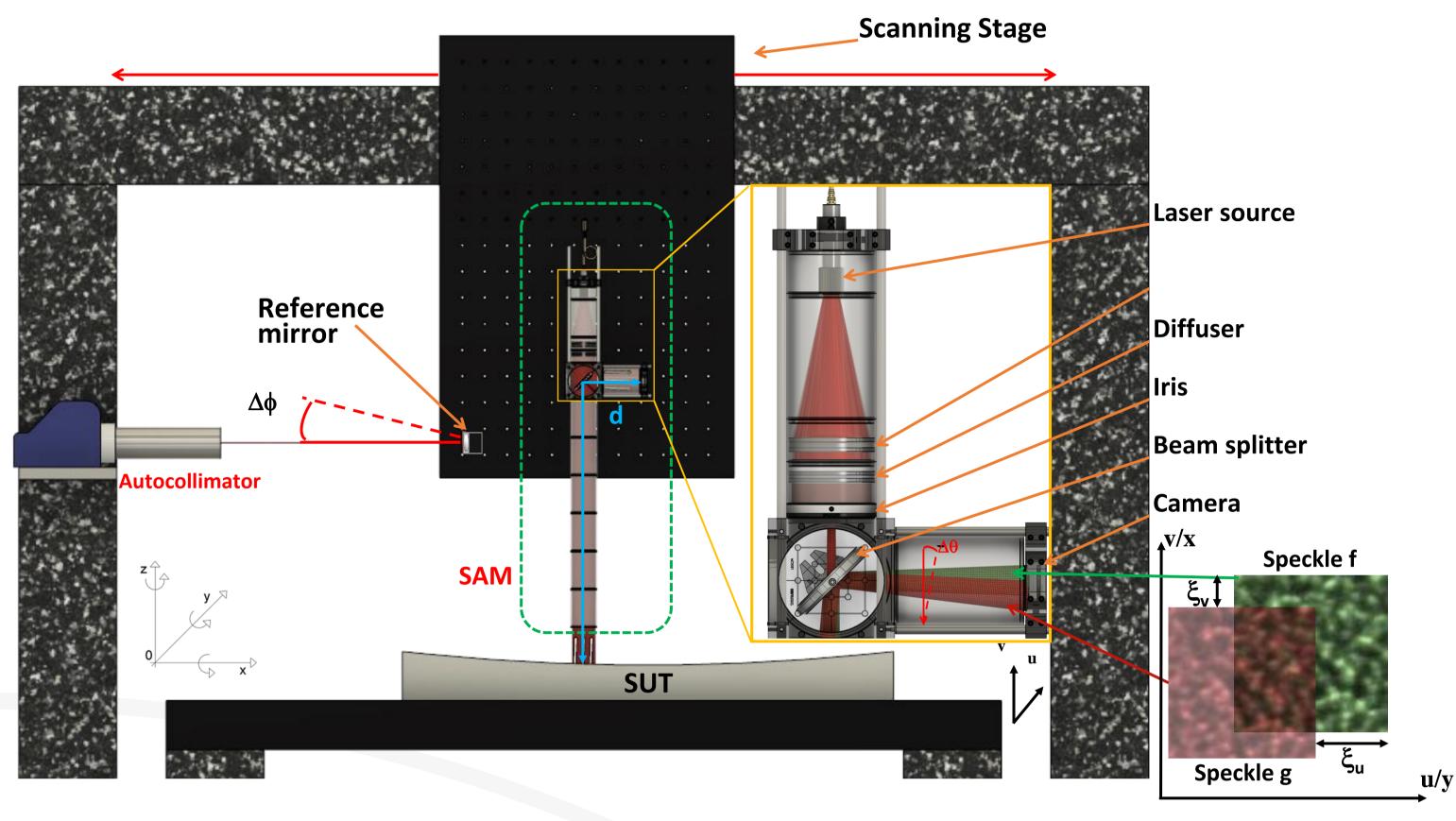


Figure 1. SAM schematic representation

Experimental setup

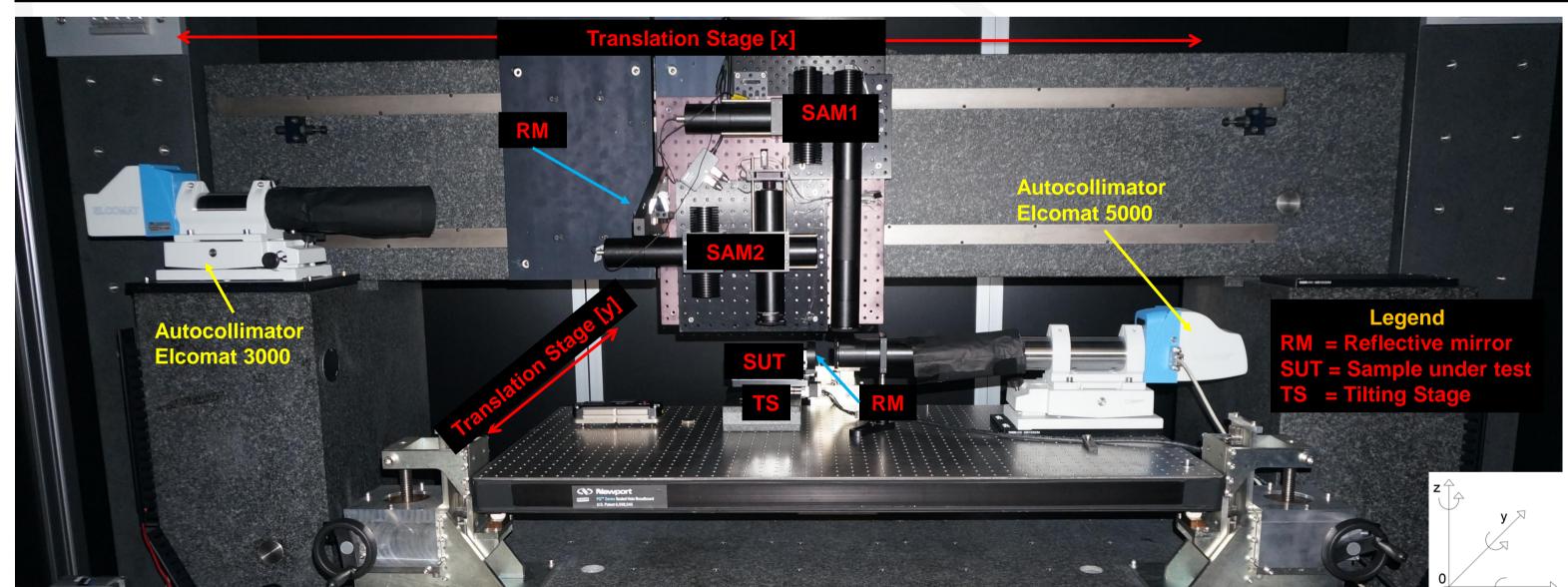


Figure 2. SAM experimental setup. Integrated SAM scan head into Diamond NOM

SUT alignment procedure and SAM stability/precision

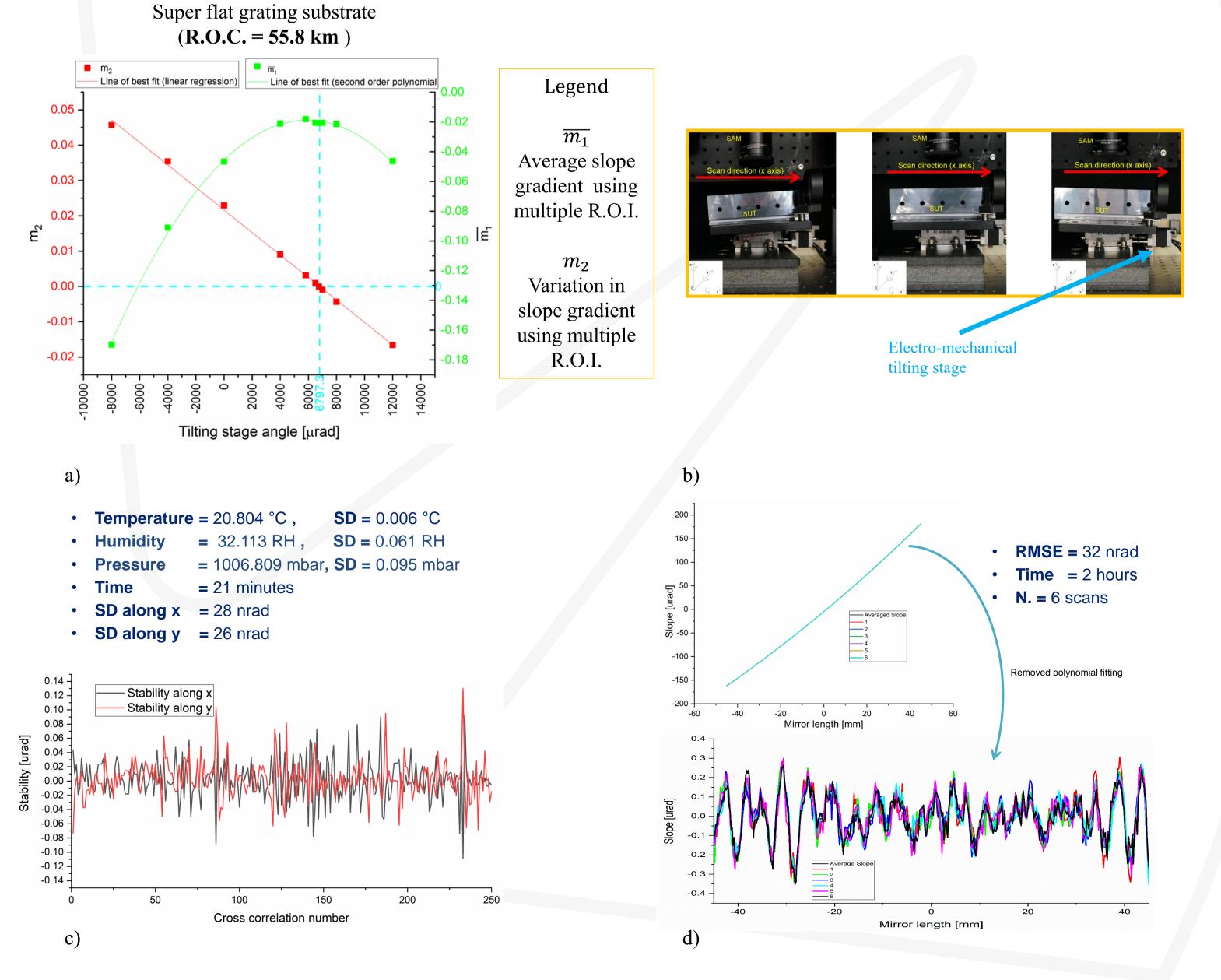
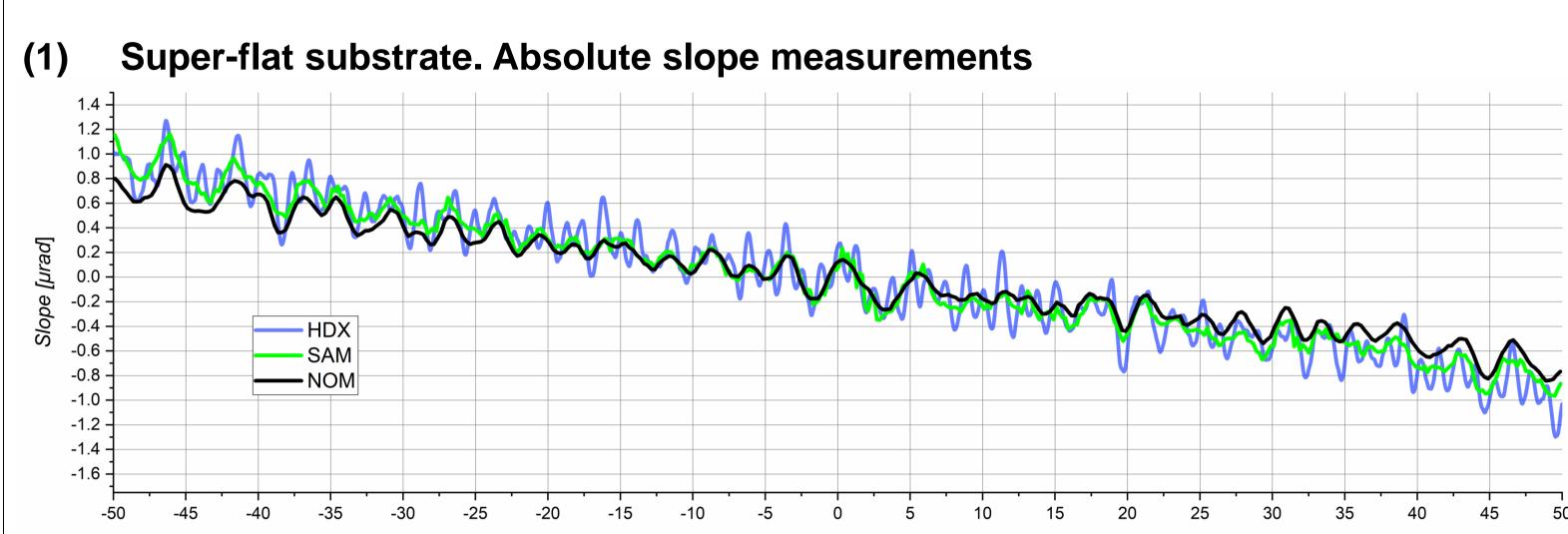
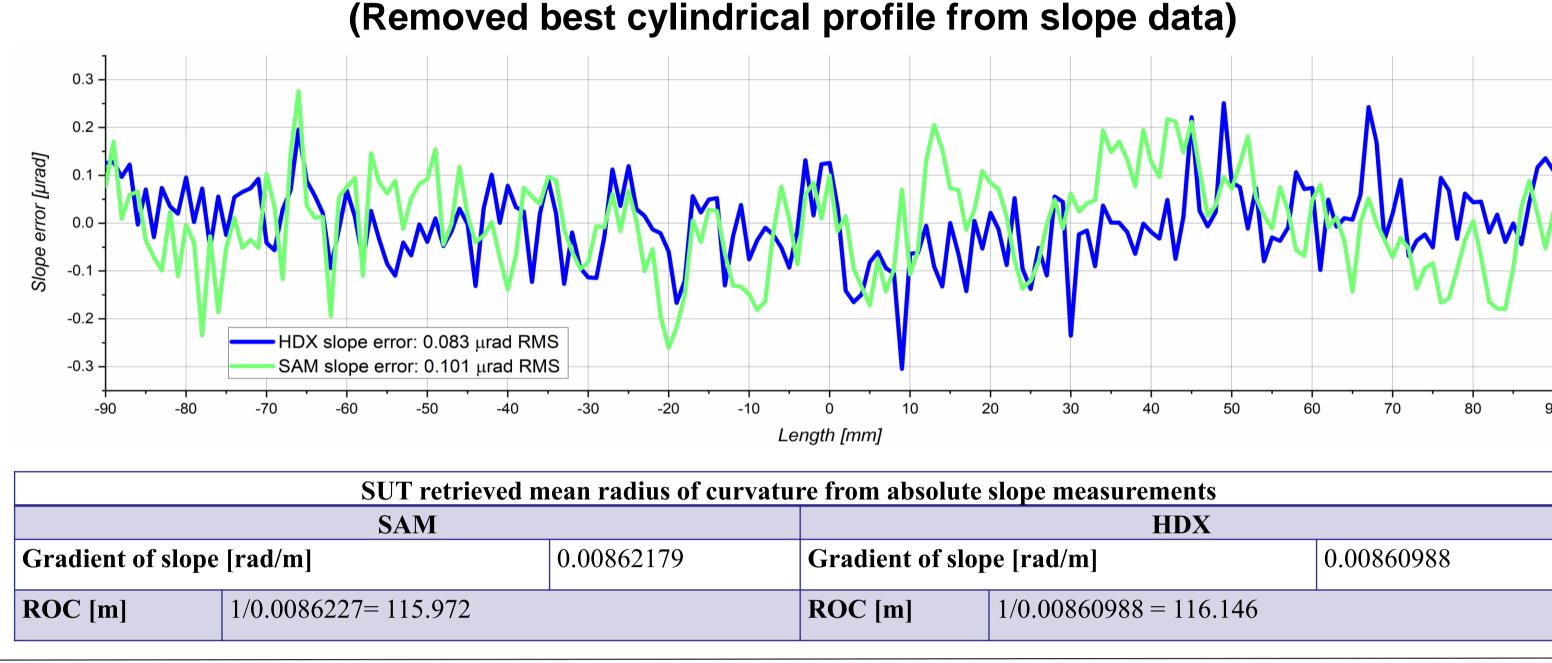


Figure 3. Alignment procedure and systematic error correction during the characterization of a super flat substrate (a). Visual representation of the alignment procedure of a SUT using SAM (b). SAM Potential stability (c) and precision (d)

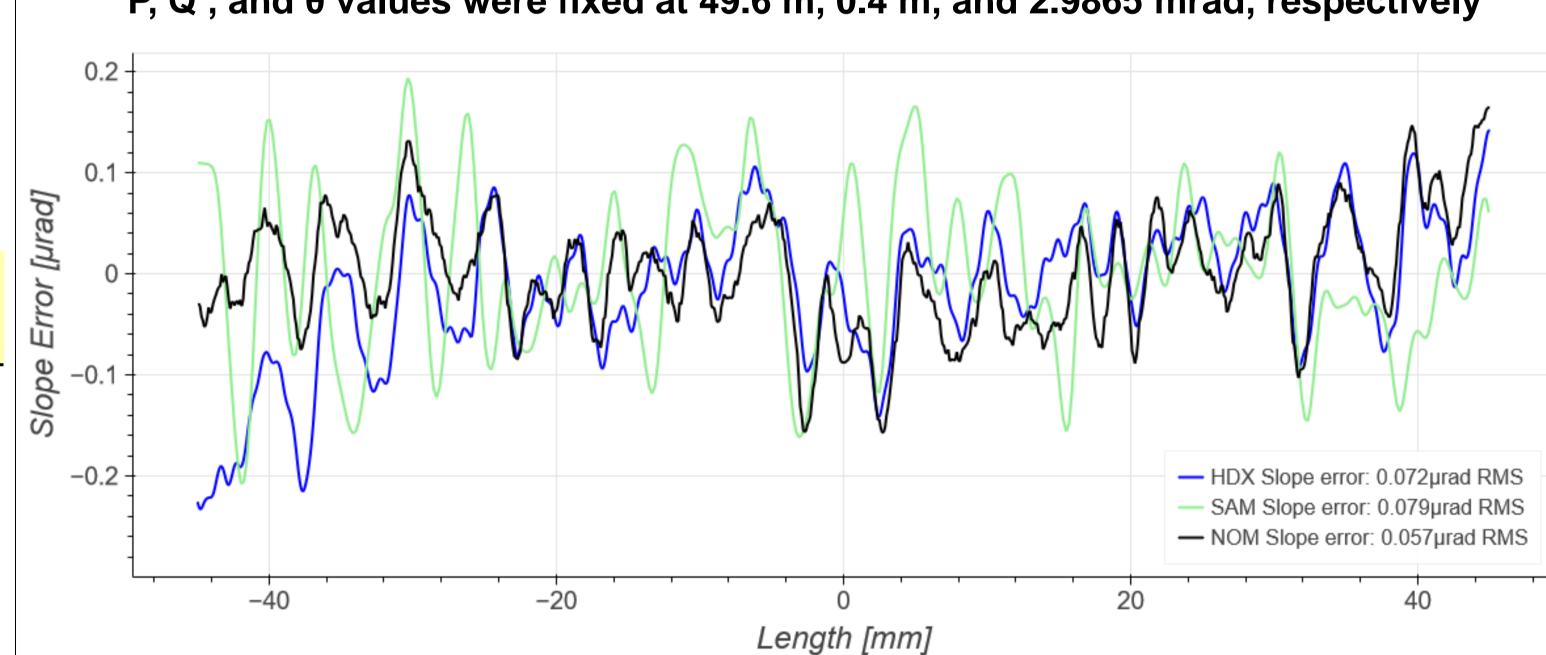
Results



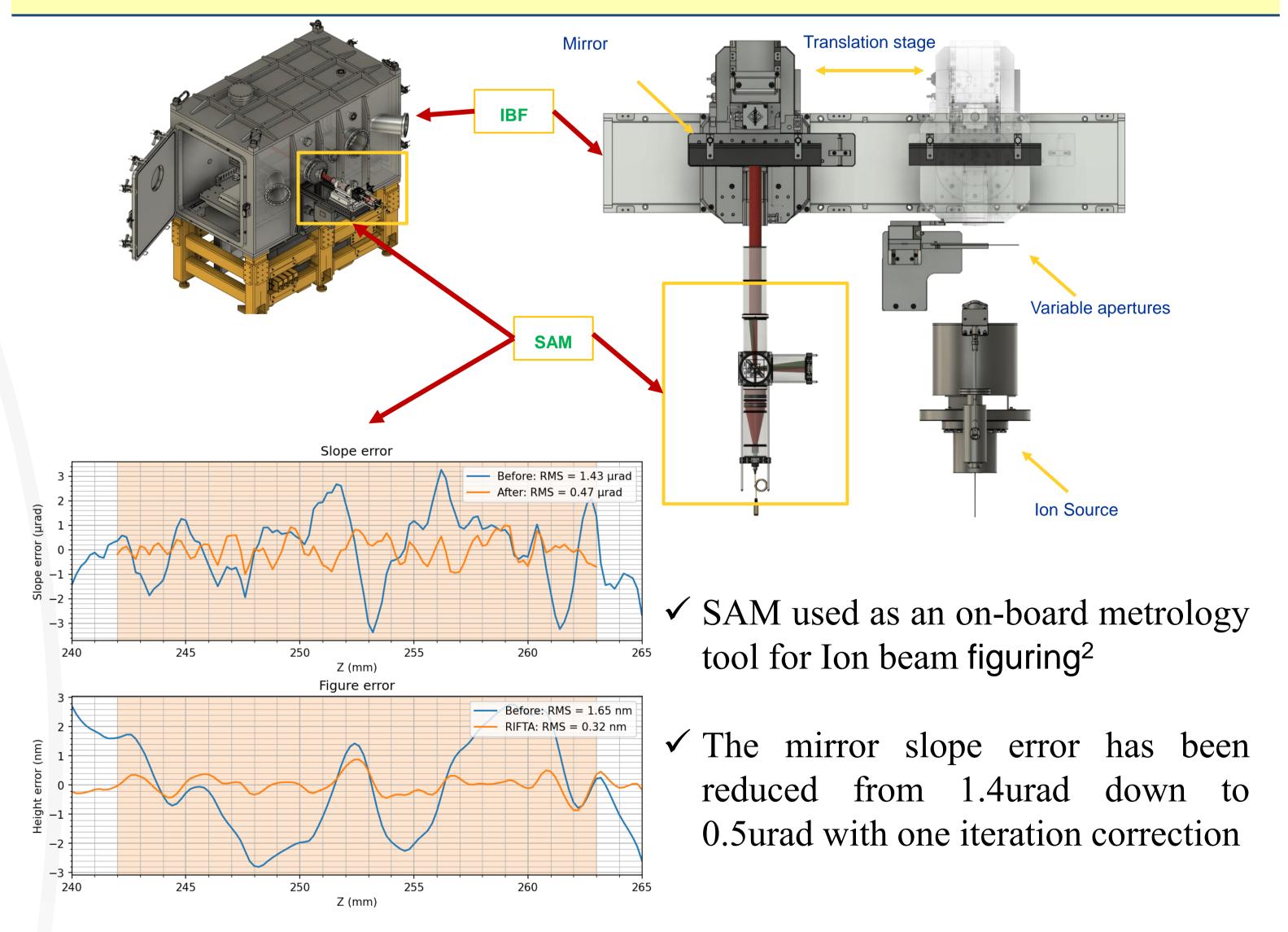




3) Elliptical mirror. Slope error measurements P, Q, and θ values were fixed at 49.6 m, 0.4 m, and 2.9865 mrad, respectively



On-board metrology for Ion beam Figuring (IBF)



References

[1] Wang, H., Moriconi, S. & Sawhney, K. Nano-precision metrology of X-ray mirrors with laser speckle angular measurement. Nature - Light Sci Appl 10, 195 (2021).

[2] Hand M, Alcock D, Hillman M, Littlewood R, Moriconi S, Wang H and Sawhney.K lon beam figuring and optical metrology system for synchrotron x-ray mirrors. SPIE Vol. 11109, Adv. Metrol. X-Ray EUV Opt. VIII, 111090A (2019)

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